Experimental Investigation of Low Power Microwave Microplasma Source

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The aim of this paper is to present a novel microwave microplasma source generated in different gases at atmospheric pressure. The design, rule of operation and experimental investigations of the new microwave microplasma source are described. The main advantage of the presented microwave microplasma source is its small size, simplicity, and low cost of construction and operation. The microplasma has a form of a small plasma jet of dimensions of a few mm, depending on the kind of gas, gas flow rate, and absorbed microwave power. Presented in this paper results of experimental investigations were obtained with an atmospheric pressure argon, krypton, nitrogen, and air microplasma, sustained by microwaves of standard frequency of 2.45 GHz. The absorbed microwave power was up to 70 W. The gas flow rate was from 2 to 25 l/min. The miniature size, simplicity of the source and stability of the microplasma allow to conclude that the presented new microwave microplasma source can find practical applications in various fields.

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1. Introduction

These days we observe a growing interest in the atmospheric pressure microplasma sources operated with various gases like argon, nitrogen, and air. Microplasma has dimensions in the range from $\mu$m to mm. There are many merits of the use of microplasma sources: economics, portability, easy to use, less made and operation costs, and small size. They are needed for surface modifications, gas cleaning, hydrocarbon reforming, microwelding, light sources, atomic spectroscopy and many others [1-5]. They can be also used in the biomedical applications such as sterilization of medical instruments, high-precision surgery, cells treatment and deactivation of bacteria and viruses [6, 7].

Among different methods of microplasma generation, microwave microplasma sources (MmPSs) are of high promising. They are simple and have long lifetime, compared to other microplasma systems. Due to this last years we designed, built and tested experimentally a small, portable and easy to use MmPS [8-10]. It had structure of a coaxial line, formed by an inner conductor, made of a brass rod with a tungsten rod top and outer conductor in the form of a brass cylinder. The MmPS was operated at standard microwave frequency of 2.45 GHz. In this paper we present a novel coaxial MmPS which is much smaller than that previously mentioned. The design, rule of operation, and experimental investigations of the new MmPS are described.

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2. Experimental setup

The diagram of the experimental setup used in these measurements is presented in Fig. 1. Its main parts were equipped with circulator, low power microwave generator of frequency of 2.45 GHz, bi-directional coupler with dual-channel power meter, the MmPS, gas supplying and flow control system, temperature, ultraviolet (UV) radiation and electromagnetic (E-M) field meters. In the experiment the microwave power $P_A$ absorbed by the microplasma was determined from $P_I-P_R$, where $P_I$ and $P_R$ are the incident and reflected microwave powers, respectively. The incident and reflected microwave powers $P_I$ and $P_R$ were measured directly using bi-directional coupler equipped with dual-channel power meter.

The photo and sketch with main dimensions of our novel MmPS is presented in Fig. 2. It is based on a coaxial line formed by the inner conductor, made of a
tungsten rod, and outer conductor in the form of a brass cylinder. The long (length 87 mm) and thin coaxial line (5 mm of outer diameter) allows to reach by plasma the hardly to access cavities e.g. in stomatology applications.

The operating gas is introduced through a duct between the inner and outer conductors. The MmPS is supplied from a typical low power 2.45 GHz microwave generator through a coaxial line using an N-type connector. The generated microplasma has a form of a small plasma jet of dimensions of a few mm, depending on the kind of gas, gas flow rate and absorbed microwave power.

3. Results

The results concerning experimental investigations of novel MmPS included: influence of operating conditions (kind of operating gas, gas flow rate, absorbed microwave power) on the size and shape of the microplasma; dependence of the reflected microwave power on the incident microwave power and on the operating gas flow rate; microplasma temperature measurements as a function of absorbed microwave power and operating gas flow rate; E-M field measurements around the MmPS and UV radiation measurements versus gas flow rate, absorbed microwave power and distance from microplasma flame.

In this paper only selected experimental results are presented. In Fig. 3 photos of the Ar, Kr, N₂, and air microwave microplasma for various operating conditions are shown. As it can be seen the size and shape of the microplasma flame depends on the kind of the operating gas and absorbed microwave power \(P_{\text{A}}\). Also, different value of minimal absorbed microwave power is needed to generate microplasma in different gases. In the case of Ar and Kr a few W of absorbed microwave power is sufficient to initiate the discharge while in the case of N₂ and air tens of W are needed.

The dependence of the reflected microwave power \(P_{\text{R}}\) on the incident microwave power \(P_{\text{I}}\) and on the operating gas flow rate was measured to estimate efficiency of microwave power transfer from the microwave generator to the plasma and thus to describe the stability of MmPS operation. Measurements were done for argon microplasma of gas flow rate up to 25 l/min and incident microwave power up to 125 W. As it was observed, although the MmPS was not equipped with any impedance matching element the reflected microwave power, for choosing experimental conditions, stays at acceptable level.

Fig. 3. Photos of the microwave microplasma generated in different gases and for various operating conditions. (a) Ar, \(Q = 10\) l/min, \(P_{\text{I}} = 12\) W, \(P_{\text{R}} = 10\) W, (b) Kr, \(Q = 10\) l/min, \(P_{\text{I}} = 15\) W, \(P_{\text{R}} = 12\) W, (c) N₂, \(Q = 10\) l/min, \(P_{\text{I}} = 300\) W, \(P_{\text{R}} = 230\) W, (d) air, \(Q = 10\) l/min, \(P_{\text{I}} = 330\) W, \(P_{\text{R}} = 260\) W.

The photo showing electromagnetic field intensity measurements around the MmPS is shown in Fig. 4a. In the photo the Holiday EMF Measurement type III-1600 meter and meter probe could be seen. Results of measurements show that all the time during the experiments the electromagnetic field intensity was never higher than 5 mW cm⁻². Thus it makes our MmPS safe for personnel and instrumentation. Figure 4b shows photo of UV radiation measurements around Ar microplasma flame. In the measurements the Sonopan UVB-20 meter was used. In the figure the meter detector placed parallel to the microplasma source can be seen.

Dependence of the UV radiation intensity on the absorbed microwave power is presented in Fig. 5a. The UV detector was placed perpendicularly to the MmPS. Measurement was done for two values of Ar flow rate, 5 and 10 l/min. The distance of the UV detector to the Ar microplasma flame was equal to 10 cm. From the figure the increase of the UV radiation intensity with increase of the absorbed microwave power can be seen. Dependence of the UV radiation intensity on the distance from Ar microplasma flame is shown in Fig. 5b. The Ar flow rate
was 5 l/min and absorbed microwave power was equal to 13.5 W. Figure shows that UV radiation strongly depends on the distance from the MmPS and decreases with increasing the distance.

Fig. 6. Photos of the (a) Ar microplasma treatment of the human skin and (b) Ar microplasma operated in a water.

In Fig. 6a the photo showing human skin treatment using low power Ar microplasma is presented. The Ar flow rate was 10 l/min and absorbed microwave power was equal to 10 W. Figure 6b shows the photo of the possibility of Ar microplasma operating in a water. As well as the possibility of living organism treatment as possibility of operation in wet environment allows to conclude that our MmPS is a promising device for the biomedical applications. Among them, potential use in dental hygiene seems to be very interesting.

4. Conclusions

The results of our experimental work show that the investigated novel MmPS can be operated with a good stability and safe level of electromagnetic field intensity. It can be operated in different gases like argon, krypton, nitrogen, and air with gas flow rates of up to tens 1/min. We showed that our MmPS can be used in human skin treatment and can be operated in water. The simplicity of the presented in this paper novel MmPS generator, operation stability and parameters of the microplasma allows to conclude that the presented device can find practical applications in various fields.

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References